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# Synthesis of Zirconium Oxide Nanoballs Using Colloid-Imprinted Carbon and Their Electrical Properties

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Uniform  $ZrO_2$  nanoballs were synthesized at 700 °C using the inverse replication method through a colloidimprinted carbon (CIC) template. The structural, dielectric, and conducting properties of the  $ZrO_2$  nanoballs were investigated and compared with those of  $ZrO_2$  film prepared by sol-gel method and powdered  $ZrO_2$  chemical. Both the monoclinic and cubic phases were found in the  $ZrO_2$  balls and film but the  $ZrO_2$  chemical showed a monoclinic phase, where the cubic structure is known to be formed at above 2,300 °C.  $ZrO_2$  nanoballs showed the lower dielectric property of k = 21.2 at 1 MHz because the 8-coordinated cubic phase in the  $ZrO_2$  nanoball produced lower polarization than the polarization of the 7-coordinated monoclinic  $ZrO_2$  chemical (k = 23.6). The dielectric stability was maintained in each  $ZrO_2$  ball, film, and chemical under the applied forward and reverse voltage range (-5 to +5 V) at 1 MHz. The ionic conductivities were 7.86 × 10<sup>8</sup>/ $\Omega$ ·cm for  $ZrO_2$  nanoballs, 3.29 × 10<sup>8</sup> / $\Omega$ ·cm for  $ZrO_2$  chemical, and 6.70 × 10<sup>-5</sup>/ $\Omega$ ·cm for the thickness of 1,053 nm  $ZrO_2$  film at room temperature with the electronic contribution being less than 0.006%.

**Keywords:** Colloid-imprinted carbon template, Zirconium oxide ball, Surface sol-gel method, Dielectric constant, Ionic and electronic conductivity

## **1. INTRODUCTION**

Since mesoporous carbon has been recognized as a catalyst in fuel cells, adsorbent, energy storage reservoir, and even a carbon based supercapacitor with the other advanced materials [1-7], a class of mesoporous carbon has been prepared through the nanocasting replication of mesoporous silica [8-11], through the imprinting of pitch with colloidal silica [12], or the imprinting of lignin gel and its carbonization [2]. The porous carbon replica was then successfully employed as a further template to achieve an inverse replica of mesoporous silica [13] or crystalline silica balls [14].

 $ZrO_2$  has emerged as a versatile material including a refractory material in insulation, abrasive, and enamel. It is used in dentistry because its excellent mechanical property is very similar to

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This is an open-access article distributed under the terms of the Creative Commons Attribution Non-Commercial License (http://creativecommons.org/licenses/by-nc/3.0) which permits unrestricted noncommercial use, distribution, and reproduction in any medium, provided the original work is properly cited. the strength of steel and its color is toothlike [15]. Nanocrystalline ZrO<sub>2</sub> can work as a catalyst due to its large surface area [16]. Stabilized zirconia has been used in oxygen sensors and solid fuel cells because it allows oxygen ions to move freely through the crystal structure at high temperature as a high ionic conductor with a low electronic conductivity, which makes it one of the most useful electroceramics. Recently, ZrO<sub>2</sub> has attracted interest in memory device applications as a candidate for the high dielectrics (k  $\approx$  25) of the gate-oxide layer in MOS transistors. ZrO<sub>2</sub> replaces SiO<sub>2</sub> which has been used as an outstanding low dielectric (k  $\approx$  3.9) but is no longer suitable with the recent downsizing due to the leakage currents from electron tunneling through the SiO<sub>2</sub> dielectric [17].

In this study, nano-sized  $ZrO_2$  particles (85 nm) were synthesized by using the reversible replication method with colloidimprinted carbon as a template, where the template was prepared from low-cost colloidal silica with a particle diameter of 85 nm imprinting on pitch. While the  $ZrO_2$  precursor is crystallized inside the carbon template, the template contributes to maintaining the round-ball shape and prevents  $ZrO_2$  nanoballs from aggregating each other at high temperature, because the strength of the carbon template is high enough to maintain its round shape. Until now, no experiment has been carried out through dielectric and conductivity studies for the nanosized  $ZrO_2$  balls. In this experiment, the structural and electrical properties of the nano-sized  $ZrO_2$  particles were also investigated and compared with those of  $ZrO_2$  film prepared using the sol-gel method and  $ZrO_2$  chemical purchased from Sigma-Aldrich, USA.

## 2. EXPERIMENTS

Colloid-imprinted carbon (CIC) was prepared by imprinting on pitch with colloidal silica according to the process described in the literature [12]. The brand name of the colloidal silica is Snowtes-ZL and its average particle diameter is 85 nm. 15.0 g of mesophase pitch carbon (Mitsubishi Chemicals) was dispersed in 150 g of ethanol and 60.0 g of colloidal silica suspension (40 wt% silica) was added. The mixture was then stirred overnight at 50°C to evaporate during the stirring stage. It was further dried at 270°C, a slightly higher temperature than the softening point of the pitch under nitrogen flow for 1 hr. Meanwhile, the silicagel particles penetrated into the pitch and a composite was formed. The composite was carbonized at 900 °C for 2 hrs under nitrogen flow, and the silica was removed by dissolving the silica with 25% HF solution for one night. For the synthesis of the  $ZrO_2$ balls through the carbon template, 0.8 g CIC was added to 1.4 g ZrOCl<sub>2</sub>·8H<sub>2</sub>O which was dissolved in ethanol for one night in advance, and the mixture was shaken until the ethanol was vaporized at room temperature. The added weight of ZrOCl<sub>2</sub>·8H<sub>2</sub>O corresponds to 75% of the pore volume of CIC to prevent the formation of ZrO<sub>2</sub> bulk. The resulting composite was heated under  $N_2$  flow at 700 °C for 4 hrs for the precursor, ZrOCl<sub>2</sub>·8H<sub>2</sub>O, to be converted to ZrO<sub>2</sub> polycrystalline in the CIC template. ZrO<sub>2</sub>/CIC composite was then heated in air at 600 °C for 6 hrs to remove the CIC template. Fig. 1 illustrates the colloidal silica imprinting process for making CIC and the preparation process of the ZrO<sub>2</sub> balls.

To synthesize the ZrO<sub>2</sub> film using the sol-gel method [18], zirconium butoxide (Aldrich) was used as a precursor. The Pt substrate (1 cm × 1 cm) as a Pt film (1,500 Å) grown on the Ti layer (100 Å)/SiO<sub>2</sub> adhesion (3,000 Å) on Si wafer (100) was purchased (Inostek Corp.). The substrate was primed with a hydroxide layer of 5 wt% 2-mercaptoethanol (Aldrich)/anhydrous ethanol solutions as the anchoring solution. 100 mM zirconium butoxide was dropped on the hydroxyl terminated Pt substrate in a dried N<sub>2</sub>filled box, spin-coated for 3 min at 3,000 rpm/min, followed by pyrolysis at 450 °C for 20 min after 2~4 coating cycles. It was then annealed at 770°C for 15 min to obtain a crystalline ZrO<sub>2</sub> phase. According to DTA analysis, zirconium butoxide was decomposed at ~380 °C. As the pyrolysis proceeded, cracks were formed. Thus, it was necessary to fabricate 10~15 multi-layer films by repeating the coating in order to cover the cracks shown in each layer and to avoid the possible electric short circuit during electrical measurement. The thickness of the ZrO2 film was measured using an  $\alpha$ -step and an ellipsometer. Silver was then deposited on the film using a mask with electrode holes of 300 µm in diameter.

Before the electrical measurements were performed for the  $ZrO_2$  nanoballs and  $ZrO_2$  chemical, the powder samples of the  $ZrO_2$  nanoballs and  $ZrO_2$  chemical were pressed into cylindrical pellets and silver was then coated on both sides of each pellet as the electrode.

The phases of the  $ZrO_2$  nanoballs, film, and chemical were confirmed by x-ray diffractometer equipped with monochromated Cu K $\alpha$  radiation. TEM images of the CIC and  $ZrO_2$  balls were obtained using a JEOL 100CX instrument.



Fig. 1. Scheme for the preparation of CIC and synthesis of  $ZrO_2$  nanoballs using the CIC template.

The measurements of capacitance and resistance were performed at 1 MHz using a HP4192A LF Analyzer and HP4284A LCR meter at room temperature. The dielectric constant was estimated from the capacitance data by using the following equation,

 $\mathbf{k} = \mathbf{Ct} / (\mathbf{k}_0 \mathbf{A})$ 

where k is the dielectric constant, C is the capacitance, t is the thickness of the pellet or film,  $k_0$  is the permittivity of free space,  $8.854 \times 10^{-12}$  F/m, and A is the area of the electrode. Electrical conductivity was estimated from the resistance data at ac (1 MHz) and dc conditions, which provided information on the ionic and electronic contributions in each ZrO<sub>2</sub> sample.

#### 3. RESULTS AND DISCUSSION

Figure 2(a) shows a TEM image of CIC prepared by imprinting the pitch with colloidal silica and Fig. 2(b) shows an image of the  $ZrO_2$  balls synthesized by following the process described in Fig. 1. The size of the  $ZrO_2$  ball in the image is quite uniform and almost equivalent to the particle diameter (85 nm) of the imprinted colloidal silica, indicating that the CIC template contributes to maintaining the ball shape during the crystallization of the precursor, and the ball size of  $ZrO_2$  can be controlled by selecting the proper size of the imprinting particle. However, a small number of  $ZrO_2$  balls were found, as seen in Fig. 2(b), because a low concentration of zirconium oxychloride precursor was added to penetrate the CIC and the precursor was decomposed inside the pore of the CIC with increasing temperature, resulting in the formation of partially pore-filled  $ZrO_2$  balls.

Figure 3 shows the XRD patterns of the ZrO<sub>2</sub> nanoballs, film, and chemical. The phase of the  ${\rm ZrO}_2$  chemical was monoclinic but the ZrO<sub>2</sub> nanoballs and film showed two crystalline forms, a monoclinic phase, and a small portion of cubic phase. Especially, the peak of the film or nanoball shown at  $2 \Theta = 30.04$  in Fig. 3 is a unique peak of cubic structure. The four other peaks marked in the XRD patterns are the peaks that are overlapped by cubic and monoclinic phases. Two strong peaks of Pt and one peak indicating Si(100), where the Pt substrate on Si was used for the film deposition, were also observed in the XRD pattern of ZrO<sub>2</sub> film. It is known that the 8-coordinated cubic structure is formed at above 2,300°C compared with the stable 7-coordinated monoclinic structure at room temperature [19]. When the particle size is reduced to nano-size, different properties from the micro-sized particles are expected due to a relatively large surface area and high reactivity in the nano-sized particles. Thus, the appearance



Fig. 2. TEM images of (a) CIC with a scale size of 100 nm and (b)  $ZrO_2$  balls with a scale size of 200 nm.



Fig. 3. XRD patterns of  $ZrO_2$  nanoball,  $ZrO_2$  film, and  $ZrO_2$  chemical. The asterisk, \*, indicates the cubic  $ZrO_2$  phase, and 'm' presents the monoclinic  $ZrO_2$  phase which overlaps the cubic phase. The other peaks indicate monoclinic phase.

of the cubic phase at 700~800 °C in the  $ZrO_2$  nanoballs and film can be observed, producing different electrical properties from those of the monoclinic  $ZrO_2$  chemical. In other words,  $ZrO_2$  with a cubic structure has lower polarization and results in reduced dielectric property compared to the case of the monoclinic  $ZrO_2$ , even though the nano-sized particles can be densely packed in pelleting at low temperature.

The dielectric constants (k) of the  $ZrO_2$  nanoballs and chemical estimated from the capacitances were 21.2 and 23.6 at 1 MHz. The k value of the  $ZrO_2$  film at 1 MHz was 3.78 for the film thickness of 705 nm and 3.98 for the thickness of 1,053 nm at room temperature. Although the pellet of the  $ZrO_2$  balls was denser and included less voids than that of the  $ZrO_2$  chemical, a lower dielectric property was observed because a small cubic portion of  $ZrO_2$  balls induced lower polarization, to a degree, compared with the monoclinic  $ZrO_2$  chemical. The lowest dielectric constant was observed in the  $ZrO_2$  film because the film also



Fig. 4. Dielectric constants of  $\rm ZrO_2$  nanoball, film, and chemical under applied forward and reverse dc bias sweeps (-5 to +5 V) with an ac oscillator level of 10 mV at 1 MHz.

included a small amount of cubic phase, moreover, the film with cracks produced new voids in the process of pyrolysis. The dielectric constant of the voids might be almost the same as that of air (k=1.006). These defects induce the reduction of the dielectric property in a film. K. Natori et al. demonstrated that "the local dielectric constant at the edge site has a reduced value due to the absence of an enforcing field effected by the nearest neighbor dipole in the adjacent layer, which fact yields a smaller effective dielectric constant in a thinner sample structure" [20]. Therefore, the dielectric property of the film is influenced by the "interfacial effects" due to the surface layer/electrode and the existence of voids in the film. Regarding the total dielectric property, the relative portions of surface area and the space charge stored at the layer/electrode in the film are larger than those in bulk. As the measuring frequency increases and at 1 MHz, the capacitance formed at the layer/electrode can be partially extracted. However, the reduction of dielectric constant at high frequency is still observed due to the existence of cracks and voids in the thin film. In Fig. 4, ZrO<sub>2</sub> nanoball, film, and chemical exhibit no significant difference in dielectric constant at voltage range, -5~+5 V, indicating that each ZrO<sub>2</sub> sample is stable under applied forward and reverse dc bias sweeps (-5 to +5 V), with an ac oscillator level 10 mV at 1 MHz.

The electrical conductivity (6) was estimated from the resistance data (R) at 1 MHz by using the following equation,

#### $\rho = R (A/t)$

where  $\rho$  is resistivity, t is the thickness of the pellet or film, and A is the area of the electrode. The electrical conductivities (where  $\delta = 1/\rho$  at 1 MHz with an ac level of 10 mV) were 7.86 ×  $10^{-8}$  / $\Omega$ ·cm for the ZrO<sub>2</sub> nanoballs,  $3.29 \times 10^{-8}$  / $\Omega$ ·cm for the ZrO<sub>2</sub> chemical, and  $6.70 \times 10^{-5}$  / $\Omega$ ·cm for ZrO<sub>2</sub> film with a thickness of 1,053 nm at room temperature. Compared with the conductivity of the ZrO<sub>2</sub> chemical, those of the ZrO<sub>2</sub> nanoball and the ZrO<sub>2</sub> film were approximately 2.4 times higher and 2,000 times higher, respectively. The results reveal that a fraction of the charge is not stored in the conducting system at high frequency, causing the reduction of charge polarization. ZrO<sub>2</sub> film has enough defects in which the charge carriers can diffuse easily through the defects. The electronic conductivities of the pellet-shaped ZrO<sub>2</sub> nanoballs and ZrO<sub>2</sub> chemical were also performed through dc measurement at the applied voltage range of -2~+2 V. The resistance, R = V/I, was obtained from the reciprocal of the slope in



Fig. 5. I-V graphs for the pellets of the  $ZrO_2$  nanoballs and  $ZrO_2$  chemical at applied voltage range of  $-2 \sim +2 V$ .

the I-V graphs shown in Fig. 5. The total electrical conductivity is composed of the electronic part and the ionic part. The mobile ion is much heavier than the electron and moves very slowly at room temperature. The charge of mobile ions therefore cannot be stored at high frequency, such as at 1 MHz. However, when dc is applied on a sample, the mobile ions transferred at the opposite electrode no longer move, except for the electrons, resulting in electronic conductivity. The electronic conductivities were  $2.49 \times 10^{-12}$  / $\Omega$ ·cm for the ZrO<sub>2</sub> nanoballs and  $1.82 \times 10^{-12}$  / $\Omega$ ·cm for the ZrO<sub>2</sub> chemical at room temperature, confirming that the electronic contribution in  $ZrO_2$  was very low (< 0.003~0.006%). Thus, ZrO<sub>2</sub> is an electronic insulator and its electrical conductivity comes from the ionic contribution by allowing oxygen ions to move through the ZrO<sub>2</sub> system. Finally, the ZrO<sub>2</sub> nanoballs with uniform pore size were synthesized using CIC in this research. The densified pellet of the ZrO<sub>2</sub> nanoballs showed higher ionic conductivity with lower electronic contribution and lower dielectric constant than those of the ZrO<sub>2</sub> chemical due to its unique structural and physical characteristics.

## 4. CONCLUSIONS

Uniform  $ZrO_2$  nanoballs were prepared using the inverse replication method through a colloid-imprinted carbon (CIC) template, indicating that the size, and the type of inorganic nanoball could be controlled depending on the selection of various imprinting compounds and precursors. Due to the increased reactivity caused by the large surface area in the nano-sized particles, the  $ZrO_2$  nanoballs can be transformed, reacted with other compounds, and densified easily at low temperature. The  $ZrO_2$  nanoballs synthesized at 700~800 °C showed two structural phases, cubic and monoclinic, even though the cubic structure is formed at above 2,300 °C. Their physical and structural characteristics also influenced the electrical properties such as increasing the ionic conductivity and decreasing the polarization. However, all types of  $ZrO_2$ , including nanoball, film, and chemical, maintained their dielectric stabilities at a voltage range of -5~+5 V.

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## REFERENCES

- [1] T. Hyeon, S. Han, Y. E. Sung, K. W. Park, and Y. W. Kim, *Angew. Chem. Int. Ed.*, **42**, 4352 (2003). [DOI: http://dx.doi.org/10.1002/anie.200250856].
- [2] D. Saha, Y. Li, Z. Bi, J. Chen, J. K. Keum, D. K. Hensley, H. A. Grappe, H. M. Meyer, S. Dai, M. P. Paranthaman, and A. K. Naskar, *Langmuir*, **30**, 900 (2014). [DOI: http://dx.doi.org/10.1021/ la404112m].
- [3] S. Han, Y. Yun, K. W. Park, Y. E. Sung, and T. Hyeon, Adv. Mater., 15, 1922 (2003). [DOI: http://dx.doi.org/10.1002/ adma.200305697].
- Y. Piao, D. Lee, Jun. Kim, Jae. Kim, T. Hyeon, and H. S. Kim, *Analyst*, **134**, 926 (2009). [DOI: http://dx.doi.org/10.1039/ B813451K].
- J. S. Yu, S. Kang, S. B. Yoon, and G. Chai, *J. Am. Chem. Soc.*, 124, 9382 (2002). [DOI: http://dx.doi.org/10.1021/ja0203972].
- [6] Y. Piao, H. S. Kim, Y. E. Sung, and T. Hyeon, *Chem. Comm.*, 46, 118 (2010). [DOI: http://dx.doi.org/10.1039/B920037A].
- [7] Y. Fang, Y. Lv, F. Gong, Z. Wu, X. Li, H. Zhu, L. Zhou, C. Yao, F. Zhang, G. Zheng, and D. Zhao, to be published in *J. Am. Chem. Soc.*, (Feb. 13, 2015). [DOI: http://dx.doi.org/10.1021/jacs.5 b01522].
- [8] R. Ryoo, S. H. Joo, and S. Jun, J. Phys. Chem. B, 103, 7743 (1999).
  [DOI: http://dx.doi.org/10.1021/jp99 1673a].
- R. Ryoo, S. H. Joo, M. Kruk, and M. Jaroniec, Adv. Mater, 13, 677 (2001). [DOI: http://dx.doi.org/10.1002/1521-4095(200105)13:9<672::AID-ADMA677>3.0.CO;2-C].
- [10] S. S. Kim and T. J. Pinnavaia, *Chem. Commun*, 2418 (2001). [DOI: http://dx.doi.org/10.1039/B107896H].
- [11] J. Lee, S. Han and T. Hyeon, J. Mater. Chem., 14, 478 (2004). [DOI: http://dx.doi.org/10.1039/B31154 1K].
- [12] Z. Li and M. Jaroniec, J. Am. Chem. Soc., 123, 9208 (2001). [DOI: http://dx.doi.org/10.1021/ja 0165178].
- [13] M. Kang, S. H. Yi, H. I. Lee, J. E. Yie, and J. M. Kim, *Chem. Commun.*, **1944** (2002). [DOI: http://dx.doi.org/10.1039/B203962A].
- [14] C. H. Kim and T. Oh, Bull. Korean Chem. Soc., 32, 3483 (2011).
  [DOI: http://dx.doi.org/10.5012/bkcs.2011.32.9.3483].
- [15] S. A. Ali, S. Karthigeyan, M. Deivanai, and R. Mani, *Pakistan Oral & Dental J.*, 34, 178 (2014). [http://www.podj.com.pk].
- [16] H. Zheng, K. Liu, H. Cao, and X. Zhang, J. Phys. Chem. C, 113, 18259 (2009). [DOI: http://dx.doi.org/10.1021/jp9057324].
- [17] D. Panda and T. Y. Tseng, *Thin Solid Films*, **531**, 1 (2013). [DOI: http://dx.doi.org/10.1016/j.tsf.2013.3.01.004].
- [18] C. H. Kim and M. Lee, *Bull. Korean Chem. Soc.*, 23, 741 (2002).
  [DOI: http://dx.doi.org/10.5012/bkcs.2002.23.5.741].
- [19] G. Rayner-Canham and T. Overton, *Descriptive Inorganic* Chemistry 4<sup>th</sup> ed., Translated by S. Kim et al. (Free Academy, Korea, 2008) p.611.
- [20] K. Natori and D. Otani, N. Sano, *Appl. Phys. Lett.*, **73**, 632 (1998).
  [DOI: http://dx.doi.org/10.1063/1.121930].